CLAIMS

1. Silica particle having a water-absorbing rate of less than 1.0 % measured 500 hours after being kept at a temperature of 50℃ and at a humidity of 90 %, and at a temperature of 85℃ and at a humidity of 85 %, D90/D10 of 3 or less, a true specific gravity of 2.1 g/cm^3 or more, and an average particle diameter of 10 μm or less.

2. The silica particle according to claim 1, which is surface treated by using a silane coupling agent and/or a silane compound.

3. A method for producing the silica particle according to claim 1, comprising a step (1) of obtaining silica particles by a hydrolysis reaction of tetraethoxysilane in a solution containing ammonia, and water in an amount of 0.5 to 15 mol per 1 mole of the used materials, and/or a derivative thereof, and a step (2) of calcinating the obtained silica particles in said step (1) at 900 to 1050℃.

4. The method for producing the silica particle according to claim 3, wherein the calcinating ~~is~~ proceed~~s~~ed at the calcinating temperature of 950 to 1050℃.

5. The method for producing the silica particle according to claim 3 or 4, comprising surface treating with use of a silane coupling agent and/or a silane compound.

6. The method for producing the silica particle according to claim 5, wherein the surface treating ~~is~~ proceed~~s~~ed by means of a spray drying.

7. A resin composition containing the silica particle according to claim 1 or 2 and a resin.